

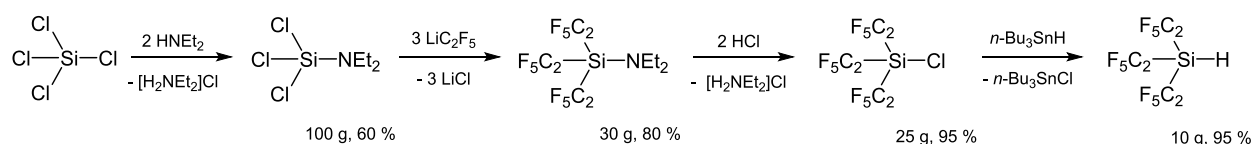
## Improved synthesis and reactivity of the tris(pentafluoroethyl)silanide ion

Natalia Tiessen, Nico Schwarzze, Berthold Hoge\*

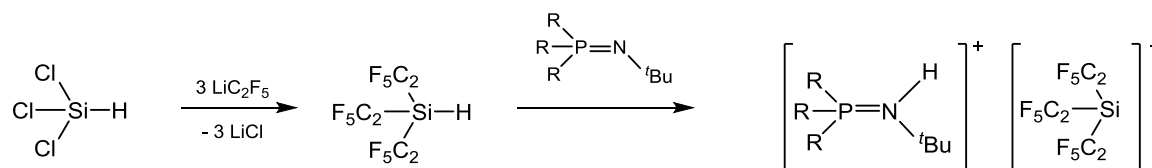
Bielefeld University, Center for Molecular Materials, 33615 Bielefeld, Germany,

E-Mail: [b.hoge@uni-bielefeld.de](mailto:b.hoge@uni-bielefeld.de)

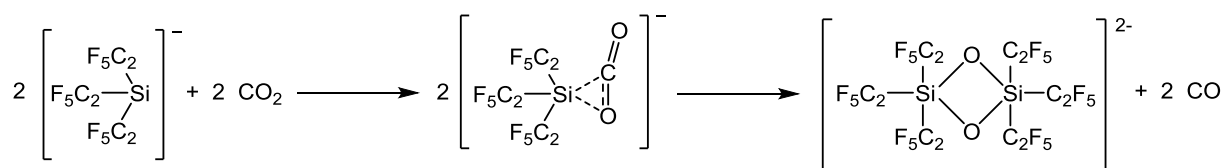
The literature-known synthesis of tris(pentafluoroethyl)silanide salts<sup>[1]</sup> proceeds via the deprotonation of Si(C<sub>2</sub>F<sub>5</sub>)<sub>3</sub>H, which is synthesized via four steps:<sup>[2]</sup>



The reaction of commercially available SiCl<sub>3</sub>H with *in situ* generated LiC<sub>2</sub>F<sub>5</sub><sup>[3]</sup> allows an access of Si(C<sub>2</sub>F<sub>5</sub>)<sub>3</sub>H within one step. The subsequent treatment of the resulting Et<sub>2</sub>O solution with neutral phosphazene bases R<sub>3</sub>P=N<sup>t</sup>Bu (R = -N=P(NEt<sub>2</sub>)<sub>3</sub> and -NC(NMe<sub>2</sub>)<sub>2</sub>) leads to a two-step synthesis of the corresponding [R<sub>3</sub>PN(H)<sup>t</sup>Bu]<sup>+</sup>[Si(C<sub>2</sub>F<sub>5</sub>)<sub>3</sub>]<sup>-</sup> salts.



The [Si(C<sub>2</sub>F<sub>5</sub>)<sub>3</sub>]<sup>-</sup> ion exhibits Lewis amphoteric character and adds carbonyl derivatives side-on. An intermediary addition of CO<sub>2</sub> leads to a liberation of CO and a dimerization of the resulting silanolate ions.



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- [3] M. Heinrich, A. Marhold, A. Kolomeitsev, A. Kadyrov, G.-V. Rösenthaller, J. Barten (Bayer AG), DE 10128703A 1, **2001**; M. H. Königsmann, Dissertation, Universität Bremen, **2005**; A. A. Kolomeitsev, A. A. Kadyrov, J. Szczepkowska-Sztolcman, H. Milewska, G. Bissky, J. A. Barten, G.-V. Rösenthaller, *Tetrahedron Lett.* **2003**, *44*, 8273-8277